

PE-Kleen G2 Filters PE-Kleen SWD Capsules

Description

The PE-Kleen G2 filter combines the latest advances in polyethylene membrane technology with Pall's unique crescent-shaped Ultipleat® filter technology. The result is a cartridge with the outstanding particle retention characteristics required by the semiconductor industry.

The PE-Kleen G2 filter is specifically designed for the filtration of ultra-high-purity chemicals, including organic stripper and DHF.

The PE-Kleen SWD capsules are space-saving filter units. They are ideally suited for installing into single wafer cleaning systems.

Features

- Excellent gel-retention characteristics
- High flow rates
- Low extractables
- 100% integrity tested
- Manufactured in a cleanroom environment
- 100% prewetted with ultrapure water in package
- Compact space-saver capsules





PE-Kleen G2 Filter

Specifications

Materials of Construction

Components	Materials
Filter Medium	HDPE (High density polyethylene)
Support and drainage	HDPE
Core,cage and end caps	HDPE
Housing	HDPE
O-ring options	FEP encapsulated fluoroelastomer, Kalrez², Chemraz³

³ Chemraz is a trademark of Greene, Tweed & Co

Product Name	PE-Kleen G2 Filters	PE-Kleen SWD Capsules
Removal Ratings	10 nm	5 nm, 10 nm
Configurations	ABDG type cartridge	U-flow capsule
Nominal Filter Areas	ABDG1 2.6 m² / 28 ft² ABDG2 5.2 m² / 56 ft² ABDG3 7.8 m² / 84 ft²	0.28 m² / 3.0 ft²
Maximum Operating Temperature	60 °C / 140 °F	
Maximum forward differential pressure	0.34 MPa / 49 psid @ 40 °C / 104 °F	
Maximum Operating Pressure		0.35 MPaG / 51 psig < 38 °C / 100 °F 0.17 MPaG / 25 psig < 60 °C / 140 °F

¹ Package is completely filled with ultrapure water.

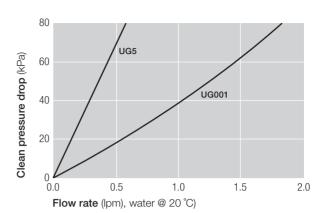
² Kalrez is a rademark of DuPont Performance Elastomers.

Typical Flow Characteristics - 1 cP fluid, 20 °C

PE-Kleen G2 Filters

Flow rate (gpm) 3.5 80 70 Clean pressure drop (kPa) Clean pressure drop (psid) 60 UG001 50 40 30 3 20 10 0 5 10 15 20 Flow rate (L/min)

PE-Kleen SWD Capsules



Part Numbers / Ordering Information⁴

PE-Kleen G2 Filter

ABDG 1 UG 2 3 E 4 5

т_	_	ı .	-
12	n	10	-
ıa	v		

Code	Nominal length (mm / in)
1	241 / 9.5
2	484 / 19.1
3	723 / 28.5

Table 2

Code	Removal ratings
001	10 nm

Table 3

Code	Configurations
3	222 O-ring open end flat closed end

Table 4

Code	O-ring materials
H1	FEP encapsulated fluoroelastomer
H11	Kalrez
H12	Chemraz

Table 5

Code Packaging	
K3	Prewet⁵
Blank	Dry

⁴Part numbers in combination with all codes are not always available. Please contact Pall for part number availability.

PE-Kleen SWD Capsules

SWD03 1 4E71 2

Table 1

Code	Removal Ratings
UG5	5 nm
UG001	10 nm

Table 2

Code	Prewet Option
None	Dry
-K13C	Prewet filter (packaged in DI water), Low metal extractables ⁶

Connections (Inlet / Outlet, Vent: 1/4 in , Super Pillar 7 300 P series (Nippon Pillar)

⁵When K3 is not included in the part number, the filter will be packaged dry.

⁶ Please contact Pall for the extractable conditions.

⁷ Pillar is a trademark of Nippon Pillar Packing Co.



Microelectronics

25 Harbor Park Drive
Port Washington, NY 11050
+1 800 360 7255 toll free US
+1 516 484 3600 telephone
+1 516 801 9700 fax

Nihon Pall Ltd.

6-5-1, Nishishinjuku, Shinjuku-ku Tokyo 163-1325 Japan +81 3 6901 5700 telephone +81 3 5322 2109 fax

Visit us on the Web at microelectronics.pall.com

Pall Corporation has offices and plants throughout the world. For Pall representatives in your area, please go to www.pall.com/corporate_contact.asp.

Because of technological developments related to the products, systems, and/or services described herein, the data and procedures are subject to change without notice. Please consult your Pall representative or visit www.pall.com to verify that this information remains valid. Products in this document may be covered by one or more of the following patent numbers: US5543047; US5690765; US6113784; US7083564; US7318800; EP0982061; EP0667800; EP1380331.

© Copyright 2018, Pall Corporation. Pall, (PALL), and Ultipleat are trademarks of Pall Corporation. @ indicates a trademark registered in the USA. *Filtration. Separation. Solution.* is a service mark of Pall Corporation.